



Faculty of Arts, Humanities and Social Science

Institute for International Law, Intellectual Property and Technology Law (IRGET)



Dear LL.M.-IP student,

Your mandatory stay at Keio University, Tokyo, as part of the Master's program "International Studies in Intellectual Property Law" is about to begin and you have probably already made most of the preparations for the trip and your accommodation on site. Herewith we would like to give you some information about the crediting of your studies at Keio University for your overall grade.

With the LL.M. "International Studies in Intellectual Property Law" you have chosen a one-year master's program with 60 ECTS. Your study abroad accounts for 25 ECTS of this total. The grade achieved at Tokyo counts for 25% of the master's grade.

Please note that the Keio University's credit and grading system differs from the continental European system.

1. Course selection

Regarding the lectures in Tokyo, you must take at least three full courses (2 credits). In the case of 1-credit courses, two have to be selected accordingly. You can of course take more courses, in which case we would select the (IP-related) courses in which you have achieved the best results. Students studying at Keio University have also the possibility to visit lectures at Waseda University.

2. Composition of the grade at the partner university

Lecture/exam	Proportion of the total score at the partner university
Exam 1	33,3%
Exam 2	33,3%
Exam 3	33,3%
Possible further elective courses	For your overall LLM grade, only the three best grades will be included. All other results will be included in the transcript of records, but will not be considered in the overall grade.

3. Conversion of the University of Keio/ TU Dresden grades

	TU Dresden	Keio		Waseda	
1	sehr gut/ excellent	S	> 90	A+	90 – 100
1,3	sehr gut/ very good				
1,7	gut/ good	Α	> 80	Α	80 -89
2	gut/ good				
2,3	gut/ good	В	> 70	В	70 – 79
2,7	befriedigend/ satisfactory				
3	befriedigend/ satisfactory	С	> 60	С	60 – 69
3,3	befriedigend/ satisfactory				
3,7	ausreichend/ sufficient				
4	ausreichend/ sufficient	D	60		
5	nicht ausreichend/ not sufficient	Fail	< 60	Fail	< 60

We wish you a lot of fun and success during your stay at Keio University.

Your LLM IP Team